



Attorney's Docket No.: 10559-894001/P17798
INTEL

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Hai Deng et al. Art Unit: 1765
Serial No.: 10/763,467 Assignee: Intel Corporation
Filed : January 22, 2004
Title : IMMERSION LIQUIDS FOR IMMERSION LITHOGRAPHY

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

INFORMATION DISCLOSURE STATEMENT

Dear Sir:

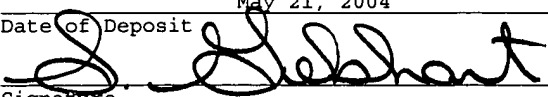
Applicants call attention to the attached Information Disclosure Statement and documents listed on form PTO-1449.

This filing is being made before the receipt of a first Office action on the merits. No fee is required.

Consideration of the foregoing and enclosures plus the return of a copy of the enclosed form PTO-1449 with the Examiner's initials in the left column per MPEP 609 are earnestly solicited along with an early action on the merits.

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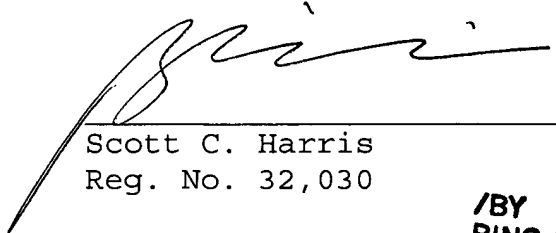
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Respectfully submitted,

Date: May 21, 2004

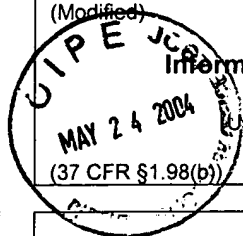


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Substitute Form PTO-1449 (Modified)	U.S. Department of Commerce Patent and Trademark Office	Attorney's Docket No. 10559-894001	Application No. 10/763,467
Information Disclosure Statement by Applicant (Use several sheets if necessary)		Applicant Hai Deng et al.	
		Filing Date January 22, 2004	Group Art Unit

**U.S. Patent Documents**

Examiner Initial	Desig. ID	Document Number	Publication Date	Patentee	Class	Subclass	Filing Date If Appropriate
	AA						
	AB						
	AC						
	AD						
	AE						
	AF						
	AG						

Foreign Patent Documents or Published Foreign Patent Applications

Examiner Initial	Desig. ID	Document Number	Publication Date	Country or Patent Office	Class	Subclass	Translation	
							Yes	No
	AH							
	AI							
	AJ							

Other Documents (include Author, Title, Date, and Place of Publication)

Examiner Initial	Desig. ID	Document
	AK	Myoung Soo Kim, et al.; Effect on Salt on the Dissolution of Novolak in Base; March 1997; SPIE, Vol. 3049; pps. 528-534
	AL	M. Switkes, et al.; Resolution Enhancement of 157 nm Lithography by Liquid Immersion; 2002; SPIE, Vol. 4691; pps. 459-465
	AM	Soichi Owa, et al.; Immersion lithography; its potential performance and issues; 2003; SPIE, Vol. 5040; pps. 724-733
	AN	M. Switkes, et al.; Immersion Liquids for Lithography in the Deep Ultraviolet; 2003; SPIE, Vol. 5040; pps. 690-699

Examiner Signature	Date Considered
EXAMINER: Initials citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.	